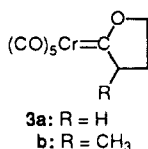


for proton transfer between 1 and the hydroxide ion. This value agrees satisfactorily with a value of 27 M^{-1} calculated from the kinetic data for the slower process¹⁶ assuming that the curvilinear dependence on hydroxide ion concentration is a manifestation of coupling to the proton transfer equilibrium. From the equilibrium constant of 22 M^{-1} and pK_w (13.72 at 20°C , $I = 0.5 \text{ M}$) a pK_a of 12.3 is calculated for 1. This is 4.3 pK_a units higher than the pK_a of *p*-cyanophenol in water, while in THF the acidities of 1 and *p*-cyanophenol are about the same.^{6b} From this comparison one may deduce that water provides much less solvational stabilization to 2 than to the *p*-cyanophenolate ion, indicating that the charge in 2 is highly dispersed.

Rate Constants. Our k_{OH} value of $135 \text{ M}^{-1} \text{ s}^{-1}$ is much higher than k_{OD} reported for the deprotonation of 3a ($3.07 \text{ M}^{-1} \text{ s}^{-1}$) and 3b ($1.97 \text{ M}^{-1} \text{ s}^{-1}$) by OD^- in acetone- d_6 / D_2O



(3.6:1 by volume) at 38°C .⁷ However, a reevaluation of the kinetic data on these latter reactions suggests k_{OD} values in the order of $10^3 \text{ M}^{-1} \text{ s}^{-1}$.¹⁷ Since the acidities of 3a and 3b are comparable to that of 1,⁷ this new estimate for k_{OD} is consistent with our result when the difference in solvent and temperature is taken into account.

Intrinsic Rate Constant. On the basis of $k_{\text{pip}} = 69 \text{ M}^{-1} \text{ s}^{-1}$ and $pK_a^{\text{pip}} = 11.52$ an intrinsic rate constant¹⁸ for deprotonation of 1 by secondary amines can be estimated as $\log k_0 = \log(k_{\text{pip}}/q) - \beta(\Delta pK + \log(p/q))$.^{18,19} Assuming $\beta = 0.5$ affords $\log k_0 = 2.08$. Since $\Delta pK + \log(p/q) = -0.48$ is quite small, any error in the assumed Brønsted β value is of little consequence. Our $\log k_0$ is quite low, lower than for any carbon acid studied to date^{18,21} except for nitroalkanes.¹¹ There is accumulating evidence of an inverse relationship between resonance stabilization of carbanions and the intrinsic rate constant for their formation,¹⁸ which is the result of the resonance stabilization lagging behind bond changes in the transition state.¹⁸ Our low $\log k_0$ value therefore suggests that 2 must derive much of its stabilization from a resonance rather than a polar effect, which is consistent with the solvent effect on the pK_a discussed above. Similar conclusions have been reached regarding the rather low intrinsic rate constants in the deprotonation of hydride transition-metal complexes.²²

Acknowledgment. This research has been supported by Grant CHE-8617370 from the National Science Foundation.

Registry No. 1, 20540-69-6.

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Insertion of Ethylene into Zr-Si and Hf-Si Bonds

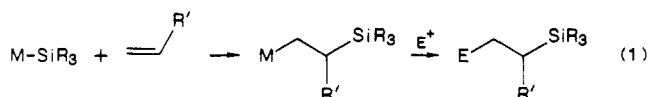
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Summary: The zirconium and hafnium silyl derivatives $\text{Cp}^*\text{Cl}_2\text{MSi}(\text{SiMe}_3)_3$ and $\text{CpCp}^*\text{Zr}[\text{Si}(\text{SiMe}_3)_3]\text{Cl}$ ($\text{M} = \text{Zr}$, Hf; $\text{Cp}^* = \eta^5\text{-C}_5\text{Me}_5$; $\text{Cp} = \eta^5\text{-C}_5\text{H}_5$) undergo clean insertion reactions with ethylene to give the β -silylalkyl complexes $[\text{Cp}^*\text{Cl}_2\text{ZrCH}_2\text{CH}_2\text{Si}(\text{SiMe}_3)_3]_2$ (1a), $\text{Cp}^*\text{Cl}_2\text{HfCH}_2\text{CH}_2\text{Si}(\text{SiMe}_3)_3$ (1b), and $\text{CpCp}^*\text{Zr}[\text{CH}_2\text{CH}_2\text{Si}(\text{SiMe}_3)_3]\text{Cl}$ (2), respectively. These reactions are photochemically and thermally induced. Complex 1a is dimeric in both the solution and solid states, whereas 1b is monomeric in solution. Crystals of 1a are triclinic, $P\bar{1}$, with $a = 9.247(4) \text{ \AA}$, $b = 12.643(6) \text{ \AA}$, $c = 14.519(6) \text{ \AA}$, $\alpha = 79.64(3)^\circ$, $\beta = 81.25(3)^\circ$, $\gamma = 75.33(4)^\circ$, $V = 1605(1) \text{ \AA}^3$, $Z = 1$, $R_F = 4.46\%$, and $R_{wF} = 5.31\%$. The quantum yield for formation of 2 ($\lambda = 380\text{--}470 \text{ nm}$, benzene- d_6) in the presence of excess ethylene is 2.5, implying a radical chain mechanism initiated by homolytic cleavage of a M-Si bond.

We have discovered transition-metal-silicon bonds that are reactive toward insertion of unsaturated substrates such as CO, CNR, and organic carbonyls.¹ These reactions involving d^0 metal silyl complexes represent new routes to Si-C bonds and therefore have potentially important synthetic applications. Insertion of alkenes into M-Si bonds are also of interest, since the resulting β -silylalkyls could provide β -functional organosilicon compounds via reaction chemistry analogous to that based on hydrozirconation² (eq 1). Also, it appears that such insertions



may occur in some transition-metal-catalyzed hydrosilylations.^{3,4} Relevant investigations by Wrighton and co-workers have recently produced the first observation of insertion of an unactivated, monoalkene (C_2H_4) into the metal-silicon bond of photochemically activated $\text{Cp}^*(\text{CO})_2\text{FeSiMe}_3$ ($\text{Cp}^* = \eta^5\text{-C}_5\text{Me}_5$).⁴ With the goal of developing chemistry based on "silylzirconation" (eq 1), we initially examined the behavior of d^0 silyls $\text{Cp}_2\text{Zr}(\text{SiMe}_3)\text{Cl}$ and $\text{Cp}_2\text{Zr}[\text{Si}(\text{SiMe}_3)_3]\text{Cl}$ toward ethylene.⁵ However,

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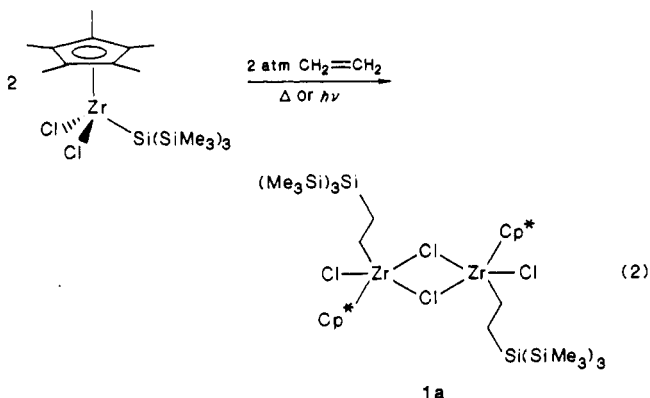
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insertion products were not observed in these cases. Our investigations of early-transition-metal silyl complexes have since produced more reactive metal-silicon bonded species that do react with ethylene. In this report we describe facile, stoichiometric insertions of ethylene into the M-Si bonds of $\text{CpCp}^*\text{Zr}[\text{Si}(\text{SiMe}_3)_3]\text{Cl}$ ^{1b} and $\text{Cp}^*\text{Cl}_2\text{MSi}(\text{SiMe}_3)_3$ (M = Zr, Hf).⁶ Related alkene insertions in analogous group 4 metal alkyl derivatives are of current interest with respect to the mechanism of alkene polymerizations.⁷

The zirconium silyl derivative $\text{Cp}^*\text{Cl}_2\text{ZrSi}(\text{SiMe}_3)_3$ combines rapidly with ethylene to give insertion product **1a** (eq 2). Under 2 atm of ethylene, dimeric **1a**⁸ is formed



cleanly in the dark ($t_{1/2} \approx 30$ min at 34 °C, benzene-*d*₆). This reaction is accelerated in the presence of ambient fluorescent room light, being complete within 5 min at 22 °C. Hafnium silyl $\text{Cp}^*\text{Cl}_2\text{HfSi}(\text{SiMe}_3)_3$ reacts more sluggishly with ethylene under analogous conditions ($t_{1/2} \approx 2$ days in the dark at 22 °C; complete conversion within 1 h in the presence of fluorescent room light at 22 °C) to give $\text{Cp}^*\text{Cl}_2\text{HfCH}_2\text{CH}_2\text{Si}(\text{SiMe}_3)_3$ (**1b**), which exists largely in monomeric form in benzene solution.⁸ These insertion reactions are quantitative by ¹H NMR, and isolated yields approach 80%. Relevant to the observed photochemistry are UV-vis spectra for silyl complexes $\text{Cp}^*\text{Cl}_2\text{MSi}(\text{SiMe}_3)_3$ (M = Zr, Hf), which display absorptions that tail well into the visible region.^{6a} These bands disappear upon formation of **1a** and **1b**,⁸ and as expected the M-C bonds of these compounds are inert toward further insertions under 8 atm of ethylene in the presence of room light.

The ethylene group of **1a** and **1b** gives rise to AA'XX' patterns in ¹H NMR spectra. For **1a**, this part of the spectrum was simulated (Figure 1). The crystal structure of **1a** consists of dimeric units that possess a crystallo-

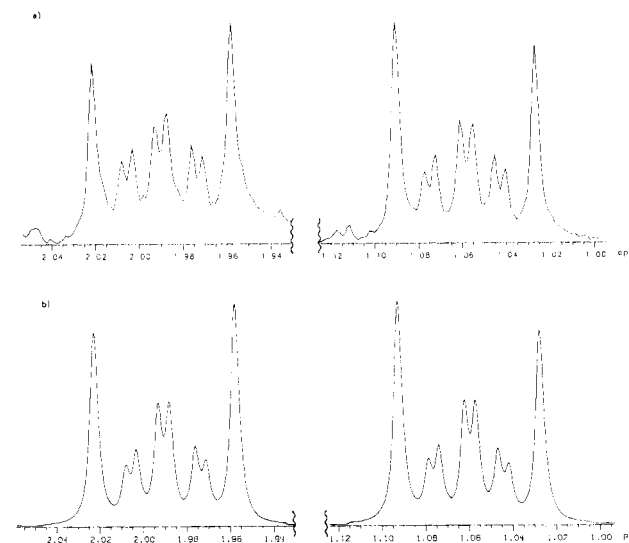


Figure 1. ¹H NMR resonances assigned to the ethylene hydrogens of **1a**: (a) measured. (b) simulated. Coupling constants ($\text{ZrCH}_2\text{CH}_2\text{Si}$, AA'XX'): $J_{AA'} = 13.0$ Hz; J_{AX} , $J_{AX'} = 5.0$ Hz; J_{AX} , $J_{AX'} = 14.5$ Hz; $J_{XX'} = 14.5$ Hz.

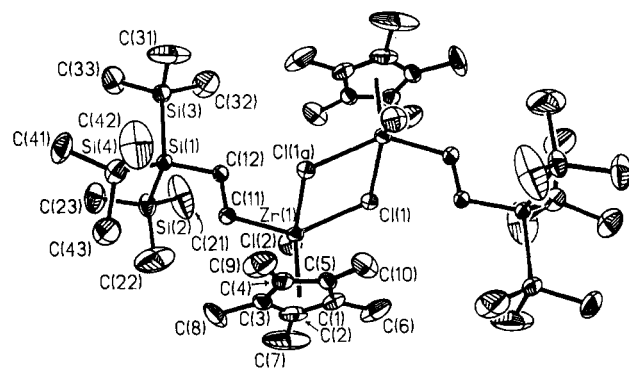


Figure 2. ORTEP view of **1a** with atom-labeling scheme. Selected bond distances (Å) and angles (deg): Zr(1)-Cl(1) 2.692 (2), Zr(1)-Cl(2) 2.579 (2), Zr(1)-Cl(2) 2.410 (2), Zr(1)-C(11) 2.222 (6), C(11)-C(12) 1.539 (8), C(12)-Si(1) 1.907 (5), Zr(1)-C(11)-C(12) 111.4 (4), C(11)-C(12)-Si(1) 114.0 (4), Cl(1)-Zr(1)-Cl(1A) 73.8 (1), Zr(1)-Cl(1)-Zr(1A) 106.2 (1), Cl(1A)-Zr(1)-C(11) 83.8 (1), C(11)-Zr(1)-Cl(2) 91.0 (2), Cl(1)-Zr(1)-Cl(2) 83.6 (1), Cl(1)-Zr(1)-C(11) 139.7 (2), Cl(2)-Zr(1)-Cl(1A) 137.0 (1).

graphic inversion center (Figure 2).⁹ The inequivalent Zr-Cl (bridge) distances, 2.579 (2) and 2.692 (2) Å, suggest that the $\text{Cp}^*\text{Cl}_2\text{ZrCH}_2\text{CH}_2\text{Si}(\text{SiMe}_3)_3$ units are rather weakly associated. The three independent Zr-Cl distances agree closely with values observed for corresponding parameters in $[\text{CpZrCl}_3]_n$.¹⁰ Distances and angles within the β -silylalkyl ligand are unexceptional and are inconsistent with the presence of an "agostic" interaction.¹¹

Upon exposure to fluorescent room light, the red zirconium silyl $\text{CpCp}^*\text{Zr}[\text{Si}(\text{SiMe}_3)_3]\text{Cl}$ reacts with 1 equiv of ethylene over ca. 3 days to afford β -silylalkyl derivative **2** (eq 3). Under 50 psi of ethylene, the reaction time is

(9) $\text{C}_{43}\text{H}_{92}\text{Cl}_4\text{Si}_8\text{Zr}_2$: triclinic, $P\bar{1}$, $a = 9.247$ (4) Å, $b = 12.643$ (6) Å, $c = 14.519$ (6) Å, $\alpha = 79.64$ (3)°, $\beta = 81.25$ (3)°, $\gamma = 75.33$ (4)°, $V = 1605$ (1) Å³; $Z = 1$; $\mu = 6.58$ cm⁻¹; Mo K α radiation ($\lambda = 0.71073$ Å). Of 6815 reflections collected ($3^\circ \leq 2\theta \leq 50^\circ$), 5666 were independent ($R_{\text{int}} = 4.07\%$) and 3653 were considered observed ($F > 6.0\sigma(F)$); $R_F = 4.46\%$, $R_{wF} = 5.31\%$.

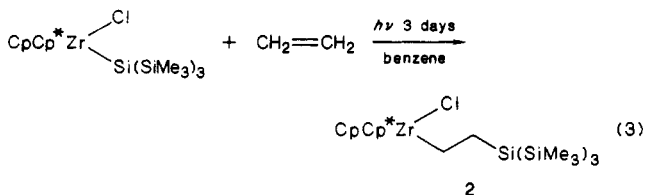
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(8) For **1a**: Anal. C, H, Cl. Mol wt calcd: 1146. Found: 1113 (isothermal distillation in benzene). ¹H NMR (benzene-*d*₆, 22 °C, 300 MHz): δ 0.28 (s, 27 H, SiMe₃), 1.06 (m, 2 H, CH₂Si), 1.84 (s, 15 H, Cp*), 1.99 (m, 2 H, ZrCH₂). ¹³C{¹H} NMR (benzene-*d*₆, 22 °C, 75.5 MHz): δ 1.38 (SiMe₃), 4.39 (CH₂Si), 11.89 (C₂Me₅), 72.92 (ZrCH₂), 124.1 (C₅Me₅). ²⁹Si{¹H} NMR (benzene-*d*₆, 59.6 MHz, 22 °C): δ -71.58 (Si(SiMe₃)₃), -12.45 (Si(SiMe₃)₃). UV-vis (pentane, nm): 224 ($\epsilon = 11000$ M⁻¹ cm⁻¹), 274 ($\epsilon = 9000$ M⁻¹ cm⁻¹). For **1b**: Anal. C, H, Cl. Mol wt calcd: 660. Found: 686 (isothermal distillation in benzene). ¹H NMR (benzene-*d*₆, 22 °C, 300 MHz): δ 0.27 (s, 27 H, SiMe₃), 0.93 (m, 2 H, CH₂Si), 1.80 (m, 2 H, HfCH₂), 1.87 (s, 15 H, Cp*). ¹³C NMR (benzene-*d*₆, 22 °C, 75.5 MHz): δ 1.49 (q, ¹J_{CH} = 120 Hz, SiMe₃), 4.79 (t, ¹J_{CH} = 122 Hz, CH₂Si), 11.47 (q, ¹J_{CH} = 127 Hz, C₂Me₅), 75.36 (t, ¹J_{CH} = 123 Hz, HfCH₂), 122.6 (s, C₅Me₅). ²⁹Si{¹H} NMR (benzene-*d*₆, 59.6 MHz, 22 °C): δ -71.49 (Si(SiMe₃)₃), -12.45 (Si(SiMe₃)₃). UV-vis (pentane, nm): 222 ($\epsilon = 15000$ M⁻¹ cm⁻¹), 257 ($\epsilon = 14000$ M⁻¹ cm⁻¹).



only ca. 10 h. This reaction is relatively clean (by ^1H NMR in benzene- d_6), and pure **2** can be isolated in ca. 50% yield as yellow crystals from pentane.¹² In the absence of light no product is formed after 5 days, indicating that insertion requires photochemical activation of $\text{CpCp}^*\text{Zr}[\text{Si}(\text{SiMe}_3)_3]\text{Cl}$. The UV-vis spectrum of $\text{CpCp}^*\text{Zr}[\text{Si}(\text{SiMe}_3)_3]\text{Cl}$ exhibits an absorption at 461 nm ($\epsilon = 500 \text{ L mol}^{-1} \text{ cm}^{-1}$), and use of cutoff filters has determined that the corresponding electronic transition gives rise to the observed photochemistry. The quantum yield for this reaction ($\lambda = 380\text{--}470 \text{ nm}$, benzene- d_6) in the presence of excess ethylene is 2.5, suggesting a radical chain mechanism initiated by homolytic cleavage of a M-Si bond.¹³

Compound **1** is remarkably stable for an alkyl complex with β -hydrogens, very little decomposition being observed after 3 days at 80 °C (by ^1H NMR in benzene- d_6). Future work will involve further development and study of this insertion chemistry. Preliminary experiments show that $\text{Cp}^*\text{Cl}_2\text{ZrSi}(\text{SiMe}_3)_3$ is unreactive toward styrene, propene, and $\text{Me}_3\text{SiCH}=\text{CH}_2$ and that $\text{Cp}^*\text{Cl}_2\text{HfSi}(\text{SiMe}_3)_3$ is inert toward diphenylacetylene and 1-hexene.

Acknowledgment is made to the Air Force Office of Scientific Research, Air Force Systems Command, USAF, for support of this work under Grant No. AFOSR-88-0273 and to the DoD University Research Instrumentation Program (Grant DAAL03-87-G-0071) for funds to purchase an X-ray diffractometer. The U.S. Government is authorized to reproduce and distribute reprints for Governmental purposes. T.D.T. thanks the Alfred P. Sloan Foundation for a research fellowship (1988-1990).

Supplementary Material Available: A listing of crystal, data collection, and refinement parameters and tables of positional and thermal parameters, bond lengths, bond angles, anisotropic thermal parameters, and hydrogen atom coordinates for **1a** (9 pages); a table of observed and calculated structure factors for **1a** (21 pages). Ordering information is given on any current masthead page.

(12) For **2**: Anal. C, H. ^1H NMR (benzene- d_6 , 22 °C, 300 MHz): δ 0.34 (s, 27 H, SiMe_3), 1.08 (m, 2 H, CH_2Si), 1.40 (m, 2 H, ZrCH_2), 1.71 (s, 15 H, Cp*), 5.90 (s, 5 H, Cp). UV-vis (pentane, nm): 225 ($\epsilon = 6000 \text{ M}^{-1} \text{ cm}^{-1}$), 329 ($\epsilon = 1000 \text{ M}^{-1} \text{ cm}^{-1}$).

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A Palladadigermetane: Palladium-Catalyzed Insertion Reactions of Digermiranes

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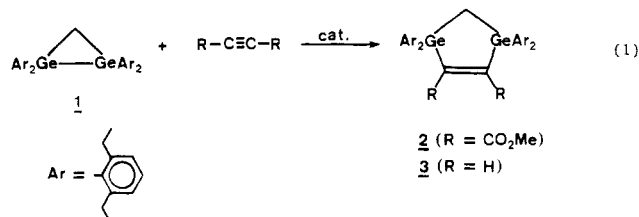
Received May 1, 1989

Summary: The palladium-catalyzed reactions of digermirane **1** with dimethyl acetylenedicarboxylate and acetylene give the ring expansion products **2** and **3**. Reaction

with methyl acrylate gives the rearranged product **4**. In the stoichiometric reaction of **1** with $\text{Pd}(\text{PPh}_3)_4$, palladadigermetane **6** is isolated as a stable compound. **6** reacts with dimethyl acetylenedicarboxylate, acetylene, and methyl acrylate to yield **2**, **3**, and **4**, respectively. The similar palladium-catalyzed reactions of thia- and selenadigermiranes **9** and **10** with acetylene give the ring expansion products **11** and **12**, respectively.

One of the most interesting reactions of the Si-Si bond of the reactive disilanes is the transition-metal-catalyzed insertion of unsaturated hydrocarbons, and numerous papers have been published so far.¹⁻⁷ In spite of these studies, no interest has been shown in the transition-metal-catalyzed insertion of unsaturated compounds into the Ge-Ge bond.⁸ Recently, we reported the preparation and chemical properties of a digermirane and its heterocyclic analogues.^{9,10} We report here the novel palladium-catalyzed ring-expansion reactions of a digermirane and thia- and selenadigermiranes. We also report the stoichiometric reaction of the digermirane with $\text{Pd}(\text{PPh}_3)_4$ to yield a palladadigermetane as stable red crystals.

When a benzene solution of digermirane **1**,^{9c} dimethyl acetylenedicarboxylate, and $\text{Pd}(\text{PPh}_3)_4$ (10 mol %) was heated to reflux for 45 h under an argon atmosphere, a crystalline product identified as digermacyclopentene **2**,¹¹ a insertion product of the acetylene into the Ge-Ge bond, was obtained in 51% yield (eq 1). It was also found that



$\text{Pd}(\text{II})$ complexes such as $\text{PdCl}_2(\text{PPh}_3)_2$ and $\text{PdCl}_2(\text{PhCN})_2$ and $\text{NiCl}_2(\text{PPh}_3)_2$ catalyzed the insertion of the acetylene into the Ge-Ge bond of the digermirane **1** equally, giving the adduct **2**. Unsubstituted acetylene also reacted with

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(11) Compound **2**: colorless crystals; mp 173-174 °C; ^1H NMR (60 MHz, CDCl_3) δ 0.87 (t, $J = 7 \text{ Hz}$, 24 H, CH_3), 1.30 (s, 2 H, GeCH_2Ge), 2.50 (q, $J = 7 \text{ Hz}$, 16 H, CH_2), 3.53 (s, 6 H, OMe), 6.9-7.4 (m, 12 H, Ar); ^{13}C NMR (25 MHz, CDCl_3) δ 11.5 (t, GeCH_2Ge), 15.1 (q, CH_3), 30.3 (t, CH_2), 51.8 (q, OMe), 125.9 (d, Ar), 128.8 (d, Ar), 141.2 (s, Ar), 147.8 (s, Ar), 157.9 (s, Ar), 169.9 (s, C=C).